

UOP PATENT DPT.

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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

Complete if Known

**EXAMINER
INITIALS**

DOCUMENT NUMBER

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DATE _____

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DATE CONSIDERED

**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

(use as many sheets as necessary)

Complete if Known

Application Number	
Filing Date	
First Named Inventor	Kurt M. Vanden Bussche et al.
Art Unit	
Examiner Name	
Attorney Docket Number	108370

U.S. PATENT DOCUMENTS

EXAMINER INITIALS	DOCUMENT NUMBER	PUBL. DATE	NAME OF PATENTEE OR APPLICANT OF CITED DOCUMENT	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
TBS	1,048,111	12/12	Tobey	261	79.2	08/15/12
TBS	2,080,616	05/37	Lynn et al.	23	66	03/17/33
TBS	2,763,699	09/56	Van Dijk et al.	260	654	10/18/54
TBS	2,847,083	08/58	Hibshman	183	24	06/18/56
TBS	3,643,406	02/72	Ririe	55	238	02/18/70
TBS	3,730,494	05/73	Sterlini	261	21	08/22/72
TBS	4,461,742	07/84	Rowe et al.	422	129	03/29/82
TBS	4,521,117	06/85	Ouwerkerk et al.	366	165	02/10/84
TBS	5,516,465	05/96	Yeoman	261	79.2	02/14/94
TBS	5,573,334	11/96	Anderson	366	162.4	05/31/95
TBS	5,605,654	02/97	Hsieh	261	79.2	02/21/96
TBS	5,632,933	05/97	Yeoman et al.	261	109	02/12/96
TBS	6,004,517	12/99	Tirtowidjojo et al.	422	129	10/28/97

FOREIGN PATENT DOCUMENTS

DOCUMENT NUMBER	DATE	COUNTRY	NAME	CLASS	SUBCLASS	TRANSLATION YES NO

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

TBS			Microreactors, New Technology for Modern Chemistry, by W. Ehrfeld, V. Hessel, H. Löwe, Wiley-VCH 2000, pp. 41-85.
TBS			Microreaction technology: industrial prospects; proceedings of the Third International Conference on Microreaction Technology/IMRET2 by T.M. Floyd et al., W. Ehrfeld, Springer 2000, pp. 171-179.
EXAMINER	T. L. Soohoo		DATE CONSIDERED 9-26-05

(Above references are attached hereto unless provided during the prosecution of parent application S.N. 09/850,470 filed May 7, 2001) TBS

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.